

1) a) Driving force for both recovery and recrystallization is the difference in internal energy between the strained and unstrained material.

Driving force for grain growth is energy associated with grain boundaries. As grains increase in size, the total boundary area decreases, yielding an attendant reduction in total energy.

b) Difference between recovery and Recrystallization

In recovery, some of the internal energy is relieved by virtue of dislocation motion where as, in recrystallization a new set of strainfree and equiaxed grains are formed.

Recrystallization have lower internal energy than recovered material.

c) Hot working

→ Temperature higher than recrystallization temp.

→ Lower hardness

→ High errors attending shrinkage

→ Metal remains soft & ductile

→ Low workability

→ Poor surface finish

Cold working

→ Working temperature lower than recrystallization temp.

→ Generally higher than that of hot working

→ low errors of shrinkage

→ Metal becomes brittle due to strain hardening

→ High workability of metal

→ Better surface finish

d) Recrystallization's driving force is strained internal energy. When material undergoes high degree of cold work, due to the high strained energies because of high strain hardening recrystallization is much more favoured.

2) Strength and toughness of a polycrystalline material single phase can be increased by Grain Boundary Strengthening mechanism

b) Equations governing

i) Grain boundary strengthening

$$\sigma_{\text{yield}} = \sigma_0 + k_y d^{-1/2} \quad \text{- Hall pitch Equation}$$

ii) Solid solution strengthening

$$\sigma_y \sim C^{1/2}$$

iii) Strain Hardening

$$\% \text{ Cold work } (CW) = \frac{A_0 - A_d}{A_0} \times 100$$

iv) Precipitation hardening

$$\tau_y = Gb/L$$

c) If a polycrystalline material have random distributed orientations, they are called crystallographic texture. Twinning is a method of producing crystallographic texture

d) i) Poly crystal As the slip of a grain in polycrystal depend on boundaries it share with other grains, it generally can endure higher stresses

ii) An Alloy is stronger than a metal as impurities put themselves at points of dislocations and increase strength of material.

iv) Coarser the distribution, is more difficult for dislocations to force through and thus, stronger they are

iii)

v)

3)

3)



$\tau_R$   
Resolved

a) One of its components in gas processing temperature

b) Ti alloy implant, rings, Guide

material  
in

v)

3)



given slip direction =  $[101]$

stress direction =  $[001]$

slip plane =  $(111)$

$$\cos \phi = \frac{1}{\sqrt{1^2+0^2+1^2} \cdot \sqrt{0^2+0^2+1^2}} = \frac{1}{\sqrt{2}}$$

$$\cos \lambda = \frac{1}{\sqrt{2}}$$

$$\tau_p = \sigma \cos \phi \cos \lambda \Rightarrow \tau_p = \left(1.1 \times \frac{1}{\sqrt{2}} \times \frac{1}{\sqrt{2}}\right) \text{ MPa}$$

Resolved shear stress

$$\tau_p = 0.45 \text{ MPa}$$

4) a) One of the common Ti alloys is  $\alpha$ -Titanium alloys. Its composition by wt% is 5 Al and 25 Sn. It is used in gas turbine engine casing and rings; chemical processing equipment require requiring strength to temperatures of  $450^\circ\text{C}$  ( $900^\circ\text{F}$ )

b) Ti alloys are used in surgical equipment, 3-D chest implant, machine parts, propellers, engines, wheel rims, automobile engine, chassis of automobile, Guide wires.

## 5) a) IC fabrication techniques

- i) Diffusion and ion implantation (iv) Lithography
- ii) Oxidation and film deposition (v) Etching
- iii) Epitaxial growth (vi) Photoresist (vii) Deposition

## b) Examples of some of semi-conductor materials

C, Si, Ge - (Elemental)

GaAs, GaN, InP, AlSb, GaAlAs, GaInN, ZnSe, CdTe  
- Compounds

## c) Carbon Nanotubes

- Two of its dimensions are on nano scale.
- Fullerene structural family with cylindrical nano structures
- Nano tubes are hollow nano rods
- These ~~are~~ comprise  $sp^2$  bonds like that in graphite

## Applications

- These are used in nanotechnology, electronics, optics, car parts, golf clubs, optical imaging, ultra sound imaging, automobile parts